## Notice of References Cited Application/Control No. | Applicant(s)/Patent Under | Reexamination | ENDO ET AL. | Examiner | Art Unit | Page 1 of 1

## U.S. PATENT DOCUMENTS

	Description   Description					
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification	
	Α	US-				
	В	US-				
	С	US-				
	D	US-				
	E	US-				
	F	US-				
	G	US-				
	Н	US-				
	I	US-				
	J	US-				
	К	US-				
	L	US-				
	М	US-				

## FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	s					
	Т					

## NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)					
	U	Hoffnagle et al., "Liquid Immersion Deep-Ultraviolet Interferometric Lithography", J. Vac. Sci. Technol. B 17(6), Nov/Dec 1999, pp. 3306-3309.					
	<b>v</b>						
	8						
	x						

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.